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Magnetotransport properties
of a polarization-doped three-dimensional electron slab in graded AlGaN

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Shubnikov–de-Haas oscillation is observed in a polarization-doped three-dimensional electron slab in a graded Al$_x$Ga$_{1-x}$N semiconductor layer. The electron slab is generated by the technique of grading the polar semiconductor alloy with spatially changing polarization. Temperature-dependent oscillations allow us to extract an effective mass of $m^* = 0.21m_0$. The quantum scattering time measured ($\tau_q = 0.3$ ps) is close to the transport scattering time ($\tau = 0.34$ ps), indicating the dominance of short-range scattering. Alloy scattering is determined to be the dominant mechanism-limiting mobility; this enables us to extract an alloy-scattering parameter of $V_Z = 1.8$ eV for the Al$_x$Ga$_{1-x}$N material system. Polarization-doping presents an exciting technique for creating electron slabs with widely tunable density and confinement for the study of dimensionality effects on charge transport and collective phenomena.

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A polar crystal with a spatially changing polarization $\mathbf{P}(\mathbf{r})$ will possess a fixed volume charge of density $\rho = \nabla \cdot \mathbf{P}(\mathbf{r})$. If sources of free carriers (electrons or holes) are available in the crystal, it is possible to use the field created by the bound polarization charge to dope the fixed volume charge region with neutralizing mobile charges. It is possible to experimentally realize such a system by alloying two materials of different polarizations and spatially varying the alloy composition (i.e., grading).

In a recent work, we reported the realization of three-dimensional electron slabs (3DES) in graded Al$_x$Ga$_{1-x}$N semiconductor layers, using this technique of polarization doping. The III–V nitride family of crystals (GaN, AlN, InN) is well suited for polarization doping owing to the large spontaneous and piezoelectric polarizations. The 3DES generated by this technique was found to possess the following characteristics: (a) the carrier density remains independent of temperature (no freezeout), (b) the mobility is much higher than the corresponding uniformly donor-doped carriers, especially at low temperatures (owing to the drastic reduction of ionized impurity scattering), and (c) the free carriers are indeed three dimensional from capacitance-voltage profiling. These properties make it a convenient system to study magnetotransport properties of the three-dimensional carrier system. We have observed clearly resolved Shubnikov–de Haas oscillations for such a polarization-doped 3DES. We are able to measure the (a) effective mass, (b) quantum scattering time, and (c) alloy-scattering potential for the 3DES electrons in Al$_x$Ga$_{1-x}$N.

Figure 1 shows a schematic of charge control and band diagram of the technique of polarization doping that we have developed. Also shown in the figure is the sample structure we have used. The sample is a Ga-face structure grown by plasma-induced molecular-beam epitaxy on a metal-organic chemical vapor deposition grown semi-insulating GaN on a sapphire substrate. The growth is along the polar $c$ (0001) axis. The top 100 nm of the structure is linearly graded Al$_x$Ga$_{1-x}$N; the composition of Al is changed from 0% to 30% by controlling the aluminum flux by a computer program.

Grading over a layer thickness $d$ creates the polarization dipole with fixed bulk charge $N_x^B = \nabla \cdot \mathbf{P} = \partial P(z)/\partial z$ and a fixed surface sheet charge $\sigma_x^S = \mathbf{P} \cdot \mathbf{n} = |\mathbf{P}|$. The neutralizing dipole formed results in the 3DES; the schematic band diagram depicts this situation. The 3DES formed has a temperature-independent electron sheet density $n_{2D} = 7.5 \times 10^{12}$ cm$^{-2}$ and a mobility $\mu = 2700$ cm$^2$/V s at $T = 20$ K, measured by conventional low-$B$ field Hall measurement.

For magnetotransport measurements of the 3DES, ohmic contacts were formed in a Vander Pauw geometry (Fig. 2).
in the range 0 \( T < B \leq 14 \) T with a base temperature of 300 mK. Magnetic fields were applied. \( R_{xx} \) and \( R_{xy} \) was measured as in the geometry depicted in the figure using the standard low-frequency lock-in technique.

In Fig. 2, we plot the measured \( R_{xx} \) against 1/\( B \) for four temperatures. Also inset is the geometry of contacts and a plot of measured \( R_{xy} \) against \( B \) for \( T = 0.4 \) K. The Hall mobility determined from the slope of the \( R_{xy} \) curve is \( \mu_H = 3000 \) cm\(^2\)/V s. If the 3DES is spread over a thickness \( d_0 \), the sheet carrier density of the 3DES is calculated to be 

\[ n_{2d} = n_{3d} \times d_0 = 1/R_{xx}B/eR_{xy} = 7.2 \times 10^{12} \text{ cm}^2. \]

This is consistent with the low-field Hall-sheet density of \( n_{2d} = 7.5 \times 10^{12} \) cm\(^2\). The spread of the 3DES is calculated from a self-consistent Poisson-Schrödinger band calculation to be \( d_0 = 75 \) nm, due to a 25 nm depletion of the 3DES from the surface potential (Fig. 1). This depletion in the graded Al\(_x\)Ga\(_{1-x}\)N layer has also been verified by capacitance-voltage profiling. Thus, the Hall three-dimensional carrier density is \( n_{3d} \approx 10^{18} \text{ cm}^3 \). The oscillations are periodic in 1/\( B \), and can be used to extract several parameters.

The oscillatory component of the transverse magnetoresistance \( \Delta R_{xx} \) is given by

\[ \Delta R_{xx}^{osc} = \frac{\chi}{\sinh \chi} e^{-\pi/\omega_c \tau_q} \left( \frac{\hbar \omega_c}{2 \varepsilon_F} \right)^{1/2} \cos \left( \frac{2 \pi \varepsilon_F}{\hbar \omega_c} \right), \]

where \( \chi = 2 \pi^2 k_F T/\hbar \omega_c \), \( \omega_c = eB/m^* \) is the cyclotron frequency, \( \tau_q \) is the quantum scattering time, and \( \varepsilon_F = \hbar^2 k_F^2 / 2m^* \) is the Fermi energy with \( k_F = (3 \pi^2 n_{3d})^{1/3} \).

The \( R_{xx} \) oscillation period \( \Delta(1/B) = 2e/\hbar (3 \pi^2 n_{3d})^{-2/3} = 0.0294 \) T\(^{-1} \) gives a direct measurement of the three-dimensional carrier concentration \( n_{3d} \approx 1.1 \times 10^{18} \) cm\(^{-3} \), which is close to the carrier density inferred from the classical Hall and \( C-V \) measurements. Also, there is no observable change in the oscillation period with changing magnetic field, indicating the absence of magnetic freezeout effects.

For analysis of the oscillatory part \( \Delta R_{xx} \), the background is removed using standard Fast Fourier Transform (FFT) techniques; the resulting \( \Delta R_{xx}^{osc} \) for various temperatures 0.4 \( K < T < 9.5 \) K is plotted against 1/\( B \) in Fig. 3. A typical FFT power spectrum (at \( T = 2.5 \) K) is shown in the inset. There is a clearly resolved peak at the fundamental oscillation period \( \tau_q = 34.01 \) T, and a weak second harmonic.

The effective mass of carriers is determined by fitting the measured amplitude damping [Fig. 4(a)] with temperature at fixed \( B \) to the temperature-damping term of Eq. (1), \( \chi / \sinh \chi \). For the peak at \( B = 8.9 \) T (arrow in Fig. 3), the effective mass is found to be \( m^* = 0.21m_0 \). We get the same effective mass for the amplitude peaks at \( B = 10.5 \) T. The band-edge electron effective mass in pure GaN (AlN) is \( m^*_{GaN} = 0.20m_0 \left( m^*_{AlN} = 0.32m_0 \right) \). From a linear interpolation for the 3DES experiencing an average Al composition of \( \chi = 0.11 \), we expect an effective mass of 0.21m\(_0\), which is in good agreement with the measured value.

![FIG. 3. The oscillatory component \( \Delta R_{xx}^{osc} \) plotted against 1/\( B \). The oscillations are periodic with a period \( \Delta(1/B) = 0.0294 \) T\(^{-1} \), and are damped with both increasing temperature (different curves) and increasing 1/\( B \). Also shown in the inset is a typical FFT power spectrum (at \( T = 2.5 \) K) showing a peak at the fundamental period, and the band-pass window used to filter the oscillatory component \( \Delta R_{xx}^{osc} \).](image1)

![FIG. 4. (a) Effective-mass plot at \( B = 8.9 \) T, where the data (dots) are fit to the \( \chi / \sinh \chi \) (line) damping term (Ref. 10). (b) Dingle plot for extraction of the quantum scattering time (Ref. 13).](image2)
close to the effective mass measured for two-dimensional electron gases at Al_{x}Ga_{1−x}N/GaN heterojunctions by the Shubnikov–de-Hasse method.\textsuperscript{12}

From Eq. (1), the slope of the Dingle plot\textsuperscript{13} [Fig. 4(b)], i.e., $\ln[A^{*}/(q/ \omega_c/2eE_F/\sinh \chi)]$ ($A^{*}$ stands for peak values of the oscillation) plotted against $1/B$ yields a quantum scattering time of $\tau_q = 0.29$ ps. An averaging of the quantum scattering times over a range of low temperatures yields a value $\tau_q^{\text{av}} = 0.3$ ps.

Distinct from the quantum scattering time is the “classical” (or momentum) scattering time $\tau_c$, which is directly measured from mobility via the Drude relation $\mu = e \tau_c / m^*$. Low-temperature Hall mobility gives $\tau_c = 0.34$ ps for the 3DES. Within limits of experimental error, the ratio $\tau_c/\tau_q \approx 1$. For isotropic scattering, it is well known\textsuperscript{14} that $\tau_c/\tau_q \approx 1$. On the other hand, $\tau_c/\tau_q \gg 1$ for scattering that peaks at small angles—scattering from Coulombic impurities is of this form. Thus, the ratio indicates that the dominant scattering mechanism at low temperatures is probably\textsuperscript{15} of a short-range (isotropic) nature.

Size-effect scattering\textsuperscript{16} that occurs if the width of the 3DES is much less than the mean-free path of electrons is negligible since our 3DES has a mean-free path $\lambda = h k_F \mu / e = 60$ nm, whereas the width of the 3DES is $d_0 = 75$ nm. The chief scattering mechanisms that can affect mobility are alloy disorder scattering, charged dislocation scattering (owing to a high density of dislocations $N_{\text{disl}} \sim 10^9$ cm$^{-2}$), and ionized impurity scattering from the remote donors at the surface states.

Hsu and Walukiewicz\textsuperscript{15} show that remote ionized impurity scattering strongly favors small-angle scattering, thus causing the ratio $\tau_c/\tau_q \gg 1$. Since $\tau_c/\tau_q \approx 1$ for our 3DES, remote ionized impurity scattering is unimportant.

The ratio of classical to quantum scattering times due to charged dislocation scattering was recently calculated\textsuperscript{17} to be

$$\tau_c / \tau_q^{\text{disl}} = 1 + 2 k_F^2 \lambda_{TF}^2,$$

where $\lambda_{TF}^2 = 2 e \epsilon_F / 3 e^2 n_{3d}$ is the Thomas-Fermi screening length of the degenerate 3DES. The ratio for our 3DES is 2.3; thus, we exclude dislocation scattering to be the most important scattering mechanism.

So we converge on alloy scattering as the dominant scattering mechanism at low temperatures. Alloy-scattering potential $V_0$ is of a short-range nature, which makes the scattering process isotropic and $\tau_c/\tau_q \sim 1$, as observed. The scattering rate due to alloy disorder with a short-range potential $V_0$ for a degenerate 3DES is given by\textsuperscript{7}

$$\frac{1}{\tau_{\text{alloy}}} = \frac{2 \pi}{h} V_0^2 \Omega(x) x (1 - x) g_{3D}(e_F),$$

where $\Omega_0(x)$ is alloy composition-dependent volume of the unit cell over which the alloy-scattering potential $V_0$ is effective, and $x$ is the alloy composition. $g_{3D}(e)$ is the three-dimensional density of states. Besides, the alloy is graded, and Matheissen’s rule, which is accurate for low-temperature transport analysis is used for a spatial averaging of the scattering rate

$$\langle \tau_{\text{alloy}}^{-1} \rangle = \frac{1}{x_0} \int_0^{x_0} \tau_{\text{alloy}}^{-1}(x) dx,$$

where $x_0 = 0.225$ is the alloy composition experienced by the 3DES electrons at the top edge of the depletion region. Using this simple result and the material constants of GaN and AlN in Table I, we conclude that to achieve a low-temperature transport mobility of 3000 cm$^2$/V·s, an alloy-scattering potential of $V_0 = 1.8$ eV is necessary. Due to the lack of experimental values, it is common practice to assume the scattering potential to be the conduction band offset between the binaries forming the alloy ($V_0 = \Delta E_c = 2.1$ eV for AlN, GaN).\textsuperscript{11}

With an alloy scattering potential of $V_0 = 2.1$ eV, the calculated mobility is much lower ($\sim 2000$ cm$^2$/V·s) than the measured value. Besides, our 3DES mobility is dominated by alloy scattering and all other scattering mechanisms are removed, making it a clean measurement of the alloy-scattering potential. This report presents the first measurement of the alloy-scattering potential in Al$_x$Ga$_{1-x}$N material system.

In summary, we demonstrated Shubnikov–de-Hasse oscillations of a degenerate three-dimensional electron gas realized by the technique of polarization bulk doping. It resulted in the measurement of the effective mass of electrons in the graded Al$_x$Ga$_{1-x}$N layer ($m^* = 0.21m_0$) and their quantum scattering time ($\tau_q = 0.3$ ps). Alloy scattering was identified as the dominant scattering mechanism from the measured
ratio of classical and quantum scattering times, making it possible to measure the alloy-scattering potential ($V_0 = 1.8$ eV).

Finally, we mention that degenerate three-dimensional electron gases are an interesting playground for the study of collective phenomena such as spin-density waves, Wigner crystallization, and integral and fractional quantum-Hall effects in three dimensions. Polarization-doped electron slabs presented in this work provide an interesting addition to the few existing techniques\textsuperscript{19} of creating such electron populations, overcoming the thermal freezeout effects associated with impurity-doped semiconductors. The wide tunability of slab thickness and electron density offered by polarization-doping makes it an attractive system to study such effects.

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9 Harmonics appear since the measured oscillations are not perfect sinusoids. Neglecting the weak second harmonic introduces no appreciable error. We use a $N=2^{15}$ size FFT window and a $f_{\text{pass}} = 28$–150 T band-pass filter to remove the background component.


